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CURRENTLY PENDING CLAIMS

- 1-62. (Cancelled)
- 63. A wafer having a surface, the surface comprising:
 - a plurality of elongated strips of polysilicon; and
 - a plurality of elongated strips of dielectric material, the strips of dielectric material alternating with the strips of polysilicon,
 - wherein the surface has been planarized by chemical mechanical planarization, and
 - wherein a first percentage of total wafer surface area that is polysilicon is less than or equal to 70 percent.
- 64. The wafer of claim 63 wherein the first percentage is greater than 50 percent.
- 65. The wafer of claim 63 wherein the first percentage is less than or equal to 60 percent.
- 66. The wafer of claim 65 wherein the first percentage is greater than 50 percent.
- 67. The wafer of claim 63 wherein the first percentage is less than or equal to 50 percent.
- 68. The wafer of claim 63 wherein the strips of polysilicon have a shortest dimension less than or equal to 500 microns.
- 69. The wafer of claim 68 wherein the strips have a shortest dimension between 0.25 and 500 microns.
- 70. The wafer of claim 63 wherein the surface of the wafer can attract enough water to wet sufficiently allowing removal of residual particles therefrom.

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